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Amdt  
SDA  
1/30/03

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. .... 09/233/377✓  
Filing Date ..... January 18, 1999✓  
Inventor ..... Gurtej S. Sandhu et al.  
Assignee ..... Micron Technology, Inc.  
Group Art Unit ..... 2813  
Examiner ..... T. Pham  
Attorney's Docket No. .... MI22-1114  
Title: Method of Forming a Refractory Metal Silicide (as Amended)

**RESPONSE TO MAY 8, 2002 OFFICE ACTION**

To: Box Non-Fee Amendment  
Assistant Commissioner for Patents  
Washington, D.C. 20231

From: Frederick M. Fliegel, Ph.D.  
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Responsive to the Office Action dated May 8, 2001, Applicants amend  
and remark as follows:

**AMENDMENTS**

09/04/2002 TBESHAH1 00000039 09233377

01 FC:103	144.00 OP
02 FC:102	252.00 OP